

# Temperature-Dependent Electron–Electron Interaction in Graphene on SrTiO<sub>3</sub>

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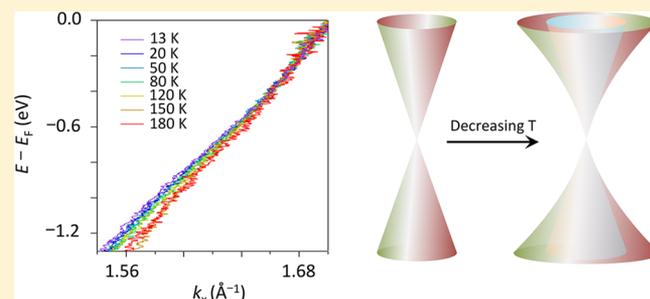
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## Supporting Information

**ABSTRACT:** The electron band structure of graphene on SrTiO<sub>3</sub> substrate has been investigated as a function of temperature. The high-resolution angle-resolved photoemission study reveals that the spectral width at Fermi energy and the Fermi velocity of graphene on SrTiO<sub>3</sub> are comparable to those of graphene on a BN substrate. Near the charge neutrality, the energy-momentum dispersion of graphene exhibits a strong deviation from the well-known linearity, which is magnified as temperature decreases. Such modification resembles the characteristics of enhanced electron–electron interaction. Our results not only suggest that SrTiO<sub>3</sub> can be a plausible candidate as a substrate material for applications in graphene-based electronics but also provide a possible route toward the realization of a new type of strongly correlated electron phases in the prototypical two-dimensional system via the manipulation of temperature and a proper choice of dielectric substrates.

**KEYWORDS:** Graphene, SrTiO<sub>3</sub>, ARPES, interface, electronic correlation



The interaction between two-dimensional (2D) materials and three-dimensional (3D) substrates not only induces novel physical properties in their interfaces<sup>1–3</sup> but also provides a viable route toward the comprehension and manipulation of the characteristics of 2D materials themselves.<sup>4</sup> For example, the dielectric response of the substrates strongly affects the electron–electron interaction in graphene, resulting in a renormalized Fermi velocity ( $v_F$ ) and reshaped Dirac cone.<sup>5–9</sup> Of particular interest,  $v_F$  near the Dirac point increases with enhanced electron–electron interaction, defying the ordinary Fermi liquid behavior where  $v_F$  decreases with stronger interaction.<sup>4</sup> Finding a suitable substrate to morph the properties of 2D materials into a desired way is a key to improve the efficiency and functionality of 2D material-based devices.<sup>10</sup>

SrTiO<sub>3</sub> is an ideal candidate as a substrate with complex layers of interesting physical properties. Its dielectric constant varies by a couple of orders of magnitude with varying

temperature ( $T$ )<sup>11</sup> and it exhibits quantum paraelectricity at low temperatures.<sup>12</sup> More interesting properties emerge when SrTiO<sub>3</sub> is interfaced with other materials, such as increased superconducting phase transition temperature of single-layer FeSe above 100 K,<sup>13</sup> two-dimensional electron gas,<sup>14,15</sup> superconductivity,<sup>16,17</sup> extremely high mobility,<sup>18</sup> electronic phase separation,<sup>19</sup> and the coexistence of magnetism and superconductivity.<sup>20</sup> Although the microscopic mechanism of such emerging phases is still a matter of intense investigation, the list of novel properties emerging from various materials interfaced with SrTiO<sub>3</sub> is ever expanding.

Considering the current interest in both 2D materials and SrTiO<sub>3</sub>, it is surprising that studies of graphene on SrTiO<sub>3</sub> are limited to a handful of transport data<sup>21–24</sup> in the literature. A

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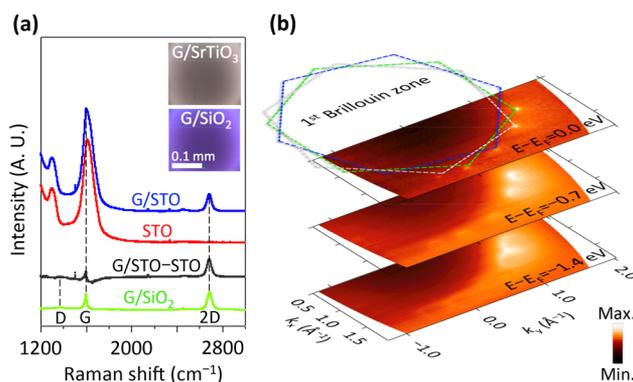
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recent transport study<sup>23</sup> reports anomalous “slope-break” in resistivity with temperature range of 50–100 K and increasing mobility at low temperatures, which is not observed in graphene/SiO<sub>2</sub>. The origin of such unconventional transport properties has been attributed to the structural phase transition of the SrTiO<sub>3</sub> substrate.<sup>23</sup> On the other hand, another study shows that the transport properties of graphene are unaffected by the SrTiO<sub>3</sub> substrate when the external magnetic field is zero.<sup>21</sup> Instead, thermal conductivity measurement on graphene shows an anomalous enhancement and subsequent breakdown of Wiedemann–Franz (WF) law within the similar temperature range, suggesting that the intrinsic electronic correlations in graphene are highly dependent on temperature as a consequence of the formation of strongly interacting Dirac electrons, so-called Dirac fluid.<sup>25</sup> Whether a similar temperature dependence can be found in spectroscopic measurements and how it may manifest itself in the measured spectra are essential information required to further understand such anomalous transport data.

In this Letter, we report a  $T$ -dependent angle-resolved photoemission (ARPES) study of graphene on an SrTiO<sub>3</sub> substrate. The graphene sample was prepared by the chemical vapor deposition method<sup>26</sup> using methane and transferred onto the SrTiO<sub>3</sub>(001) substrate after annealing the substrate under O<sub>2</sub> flow to remove any residual oxygen vacancies (see [Experimental Section](#) for detailed sample preparations). The graphene on an SrTiO<sub>3</sub> substrate is then annealed in ultra high vacuum to remove contaminants for ARPES measurements. At  $T \sim 180$  K, the deviation from the characteristic linearity in the measured energy-momentum dispersions mostly follows the conventional picture<sup>4</sup> of dielectric-assisted enhancement of electronic correlations albeit the dielectric constant of an SrTiO<sub>3</sub> surface is heavily renormalized compared to that in bulk. Such deviation is enhanced at low temperatures, which cannot be explained within the dielectric picture in multiple ways detailed below. We also report that the spectral width at Fermi energy ( $E_F$ ) and  $v_F$  of graphene on SrTiO<sub>3</sub> are comparable to those of graphene on a BN substrate, suggesting that SrTiO<sub>3</sub> can also be a plausible candidate as a substrate material for applications in graphene-based electronics.

The graphene samples on the SrTiO<sub>3</sub>(001) substrate were characterized by both Raman and ARPES. [Figure 1a](#) shows Raman spectra taken for several different samples. The blue curve (G/STO) is a raw Raman spectrum taken from graphene on SrTiO<sub>3</sub>. In order to extract signal from graphene, a Raman spectrum for a bare SrTiO<sub>3</sub> substrate (red curve: STO) was subtracted from the G/STO spectrum resulting in the black curve (G/STO–STO) that shows peaks at 1580 and 2700 cm<sup>-1</sup>. These peaks correspond to the primary in-plane vibrational mode, G band, and a second-order overtone of a different in-plane vibration, 2D band, of graphene, respectively.<sup>27</sup> The black curve agrees well with the typical Raman data taken from graphene on SiO<sub>2</sub>, which is the green curve (G/SiO<sub>2</sub>). One can also notice that graphene on SrTiO<sub>3</sub> shows negligible signal corresponding to the disorder-induced D band around 1350 cm<sup>-1</sup>.<sup>27</sup> The inset shows optical microscope images of graphene on SrTiO<sub>3</sub> and SiO<sub>2</sub> for comparison.

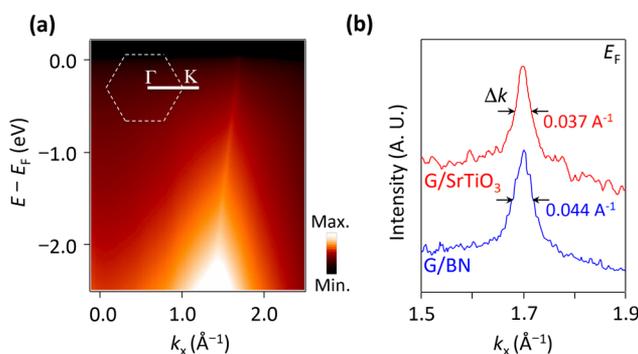
[Figure 1b](#) shows constant energy intensity maps from ARPES measured on the same sample. ARPES is a sensitive tool to characterize the quality of graphene by directly probing its electron band structure, for example, charge neutrality,<sup>28</sup> band curvature,<sup>5</sup> number of layers,<sup>29</sup> and effect on chemical/dielectric environment.<sup>4</sup> For example, one can decide the



**Figure 1.** (a) The blue curve (G/STO) is a raw Raman spectrum taken from graphene on SrTiO<sub>3</sub>. The black curve (G/STO–STO) is obtained by subtracting a reference spectrum taken from a bare SrTiO<sub>3</sub> substrate (red curve: STO) from the G/STO spectrum to extract the contribution from graphene alone. The green curve (G/SiO<sub>2</sub>) is a spectrum taken from graphene on SiO<sub>2</sub> for comparison. Insets are optical microscopy images of graphene on SrTiO<sub>3</sub> (up) and SiO<sub>2</sub> (down). (b) Constant-energy ARPES intensity maps taken at  $E - E_F = 0$ ,  $-0.7$ , and  $-1.4$  eV.

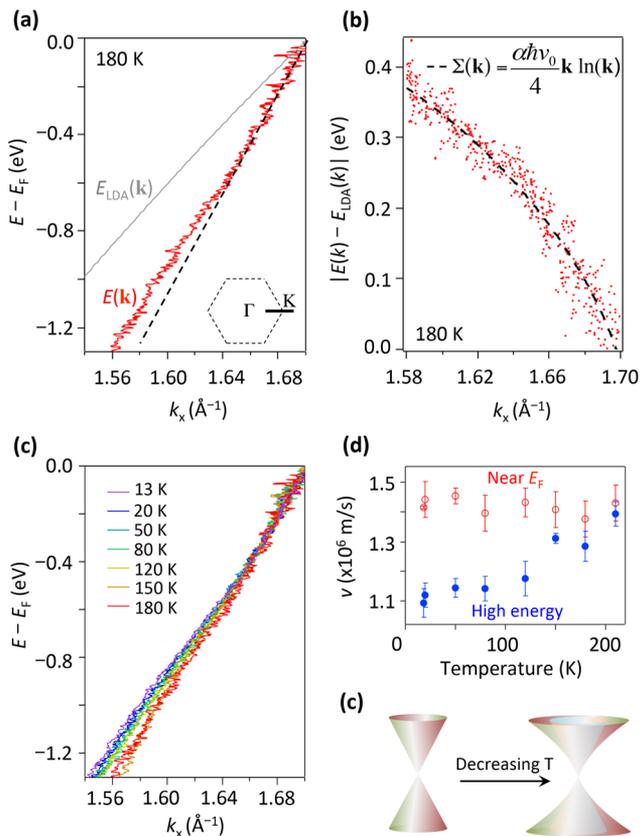
charge neutrality from the position of the Dirac point, and layer numbers from how many linear bands exist in the electron band dispersion. The ARPES also provides the information on the quality of the graphene from the line width of the spectra.<sup>30</sup> Fermi surface ( $E - E_F = 0.0$  eV) consists of several spots that expand to wider crescent-like shape at higher energies, each of which shows the characteristic conical dispersion of charge neutral single-layer graphene. There exist three major domains of graphene with different azimuthal orientations as indicated by blue, green, and gray hexagons within the probing area for ARPES measurements of  $\sim 40 \times 80 \mu\text{m}^2$  (photon beam spot size of the measurements), consistent with the azimuthal disorder of typical CVD-grown graphene.<sup>31</sup>

[Figure 2a](#) shows an ARPES intensity map taken along the  $\Gamma$ –K direction of hexagonal Brillouin zone (BZ) as denoted by the white line in the inset. Along this orientation, only one of the two branches of the graphene  $\pi$  band is observed due to the matrix element effect.<sup>32</sup> The single linear band crossing  $E_F$  evidences the single-layer nature of the graphene on SrTiO<sub>3</sub>.<sup>29</sup>



**Figure 2.** (a) ARPES intensity map of graphene on SrTiO<sub>3</sub> taken at 13 K along the  $\Gamma$ –K direction as denoted by the white line in the inset. The white dashed line is the Brillouin zone of the hexagonal unit cell of graphene. (b) Momentum distribution curves at  $E_F$  for graphene on SrTiO<sub>3</sub> (red curve) and graphene on hexagonal BN (blue curve) taken at 13 and 15 K, respectively.  $\Delta k$  denotes the full width at half-maximum of the peak as denoted by black arrows.

The red curve in Figure 2b is the momentum distribution curve (MDC) taken at  $E_F$  from the data shown in Figure 2a. The full width at half-maximum,  $\Delta k$ , of the MDC for graphene on SrTiO<sub>3</sub> (red curve) is  $0.037 \text{ \AA}^{-1}$ , even narrower than that for graphene on BN (blue curve),  $0.044 \text{ \AA}^{-1}$ .<sup>4</sup> The BN substrate is considered as one of the ideal substrate materials for graphene inducing an order of magnitude higher charge carrier mobility<sup>33</sup> and significantly improved temperature and electric-field performance compared to graphene on SiO<sub>2</sub>.<sup>34,35</sup> This is due to the flat nature of graphene on BN, whose roughness is three times less than that on a SiO<sub>2</sub> substrate.<sup>33</sup> From an ARPES point of view, the flatness of graphene and the enhanced mobility are observed as a narrow spectral width at  $E_F$ ,<sup>4</sup> where self-energy contribution is almost vanished, and as an enhanced  $v_F$  near  $E_F$ , respectively. The latter can be directly extracted from Lorentzian fits to the MDCs at each energy of the graphene  $\pi$  band, which is shown in Figure 3a. The observed  $v_F$  is  $1.42 \times 10^6 \text{ m/s}$ , which is significantly enhanced compared to  $0.85 \times 10^6 \text{ m/s}$  within the local density approximation (LDA), but similar to  $1.49 \times 10^6 \text{ m/s}$  measured from graphene on BN.<sup>4</sup>



**Figure 3.** (a) An energy-momentum dispersion of graphene on SrTiO<sub>3</sub>,  $E(k)$ , taken along the  $\Gamma$ -K direction at 180 K. The gray solid line,  $E_{\text{LDA}}(k)$ , is an LDA band and the black dashed line is a straight line extension from the lowest energy part of the dispersion, for comparison. (b) An  $|E(k) - E_{\text{LDA}}(k)|$  dispersion at 180 K. The black dashed curve is a logarithmic fit to the  $|E(k) - E_{\text{LDA}}(k)|$  dispersion. (c) Energy-momentum dispersions of graphene on SrTiO<sub>3</sub> taken along the  $\Gamma$ -K direction at several different temperatures. (d) The slope of the dispersion obtained by a line fit to the dispersion between 0.0 eV and -0.4 eV (red empty circles) and between -0.6 eV and -1.1 eV (blue filled circles) as a function of temperature. (e) Cartoon illustrating the electron band structure of graphene near charge neutrality at high (left) and low (right) temperatures.

The sharp spectral width and the high  $v_F$  comparable to those for graphene on BN suggest that SrTiO<sub>3</sub> can also be one of the ideal candidates as a substrate material for graphene-based electronic devices.

More interesting features can be observed from the details of the extracted dispersion in Figure 3a and its temperature dependence. First of all, the energy-momentum dispersion at 180 K deviates from the linearity of Dirac electrons as shown in Figure 3a. The difference between the measured dispersion,  $E(k)$ , and the dispersion from LDA,  $E_{\text{LDA}}(k)$ , gives a good approximation of an electron self-energy. Figure 3b shows the self-energy as a function of wavenumber that is well fitted by a logarithmic function,  $\Sigma(k) = \alpha\hbar v_0/4 \times (k - k_F)\ln(k_C/(k - k_F))$ ,<sup>5,36</sup> where  $\alpha$  is a fine-structure constant of  $e^2/(4\pi\epsilon\hbar v_0)$ ,  $v_0$  is the bare velocity of electrons of  $0.85 \times 10^6 \text{ m/s}$ ,  $k_C$  is the momentum cut off of  $1.7 \text{ \AA}^{-1}$ , and  $k_F$  is the Fermi wavenumber. The vanishing density of states at  $E_F$  of charge neutral graphene leads to the absence of metallic screening. With the unscreened Coulomb interaction, graphene exhibits the singularity in the interaction and resultant logarithmic correction to the electron self-energy analogous to a marginal Fermi liquid.<sup>36</sup> Indeed, the logarithmic fit gives  $\alpha = 1.1$ , implying that this system requires a full theoretical treatment beyond the random-phase approximation.<sup>37</sup> Hence the logarithmic self-energy is a good evidence of non-Fermi liquid behavior of charge neutral graphene.<sup>5,38</sup> In addition, the logarithmic correction, that is, the curvature of the dispersion, is further enhanced by increasing the strength of electronic correlations.<sup>4</sup>

The effective dielectric constant of graphene can be extracted from  $\alpha$ .<sup>4,5</sup> For the data taken at 180 K, extracted dielectric constant of graphene is only 2.33, which is comparable to that of suspended graphene, 2.2–5,<sup>8</sup> but completely different from the dielectric constant of bulk SrTiO<sub>3</sub> (300–18000).<sup>11</sup> The apparent discrepancy suggests that the dielectric screening from the SrTiO<sub>3</sub> substrate to the graphene is overwhelmingly suppressed. The formation of an interfacial layer between a metal and an insulator often leads to a few orders of magnitude reduced capacitance than the bulk value of the insulator,<sup>11,39</sup> which is known to be an intrinsic property unavoidable at the interface due to the rearrangement of atoms to compensate strains.<sup>40,41</sup> Such a dead layer has been also reported at the surface of a dielectric film such as SrTiO<sub>3</sub>.<sup>42</sup> The formation of a dead layer on the surface of SrTiO<sub>3</sub> from annealing process strongly reduces the dielectric constant from 400 (bulk) to 140 (film) at 180 K and from 18000 (bulk) to 1000 (film) at 2 K.<sup>11,43</sup> In our case, the TiO<sub>2</sub>-terminated surface was exposed not only to the air, that contaminates a surface with hydroxides, hydrogen molecules, and so forth, but also to chemicals used during the transfer of graphene on top of SrTiO<sub>3</sub>, which will result in an ill-defined crystalline structure of the surface of SrTiO<sub>3</sub> (see Supporting Information I for detailed discussion). This will lead to the change of the dielectric property of SrTiO<sub>3</sub>. Indeed, the dielectric constant of SrTiO<sub>3</sub> very close to the surface can be as low as  $\epsilon \sim 5$ .<sup>44</sup> This implies an effective dielectric constant at the SrTiO<sub>3</sub> surface of  $\sim 3$  using the simple standard approximation,  $\epsilon = (\epsilon_{\text{vacuum}} + \epsilon_{\text{surface}})/2$ , similar to the extracted dielectric constant for graphene on SrTiO<sub>3</sub> from our ARPES data. Thus, both the interfacial effect between graphene and SrTiO<sub>3</sub>, and the ill-defined surface of SrTiO<sub>3</sub> are attributed to play an important role in the dramatic change of the dielectric property of the SrTiO<sub>3</sub> surface. Our result is consistent with the transport data showing that the dielectric constant of SrTiO<sub>3</sub> does not affect the transport properties of

overlying graphene.<sup>21</sup> The depressed dielectric screening on the surface of SrTiO<sub>3</sub> leads graphene to retain its intrinsic properties such as charge neutrality and resultant strong electron–electron interaction despite graphene stands on a substrate.

The strongly suppressed dielectric constant and the charge neutrality of graphene on SrTiO<sub>3</sub> allow graphene to revive its intrinsic strength of electronic correlations despite graphene is placed on a substrate. As discussed in Figure 3, the logarithmic correction to the electron self-energy is a good evidence of non-Fermi liquid behavior of charge neutral graphene<sup>5,38</sup> and it is further enhanced with increasing strength of electronic correlations.<sup>4</sup> As shown in Figure 3c, the energy-momentum dispersion of the graphene  $\pi$ -band is further modulated upon decreasing temperature. The slope at higher energy gradually decreases, whereas the slope near Fermi energy barely changes as summarized in Figure 3d and schematically drawn in Figure 3e. In other words, the curvature of the energy spectrum becomes even stronger with decreasing temperature than the logarithmic correction can describe (see Supporting Information II for detailed discussion).

The accelerated enhancement of electron–electron correlation at low temperatures is similar to the recent experimental report on the strongly coupled Dirac Fermions in charge neutral graphene.<sup>25</sup> With decreasing temperature, thermal conductivity of graphene exhibits an abnormal upturn, which evidences the breakdown of WF law due to the formation of Dirac fluid states near charge neutral point. The upturn of the thermal conductivity was found to be  $\sim 120$  K, similar to the temperature where the slope at higher energy starts to decrease in our measurements. While the lower limit of the formation of Dirac fluid is the temperature corresponding to the disorder potential in the presence of charge puddles for the case of graphene on SiO<sub>2</sub> ( $T_{\text{dis}} \sim 40$  K),<sup>25</sup> the sharper spectral feature discussed in Figure 2 in conjunction with the negligible D band discussed in Figure 1a might allow us to speculate much smaller  $T_{\text{dis}}$  in graphene on SrTiO<sub>3</sub>, so that the Dirac fluid state persists down to the experimental low-temperature limit in our measurements. Although our results do not directly prove the formation of the Dirac fluid states in graphene on SrTiO<sub>3</sub>, both studies suggest that temperature is an important factor driving strong electron–electron correlation in charge neutral graphene.

In conclusion, we have reported the spectroscopic evidence of temperature-dependent nonlinearity of the energy spectrum of graphene on SrTiO<sub>3</sub>. The sharp spectral width and the high  $v_{\text{F}}$  comparable to those for graphene on BN suggest that SrTiO<sub>3</sub> is one of the plausible candidates as a substrate material for graphene. More importantly, strongly suppressed dielectric screening on the surface of SrTiO<sub>3</sub> allows us to manipulate the electron self-energy of graphene as a function of temperature. The modified electron self-energy is attributed to the enhanced electron–electron correlation at low temperature, which cannot simply be described by a dielectric screening picture. Our results suggest that temperature in conjunction with a proper choice of a substrate can lead to a strong electron–electron correlation in graphene. Making use of the enhanced electronic correlation of graphene despite the existence of a substrate will provide a versatile platform for the artificial modification of a functionality of graphene-based devices.

**Experimental Section.** The TiO<sub>2</sub>-terminated SrTiO<sub>3</sub>(001) crystal was obtained from CrysTec GmbH. To remove any residual oxygen vacancies, the crystal was annealed under O<sub>2</sub>

flow for 6 h at 600 °C.<sup>45</sup> The quality of SrTiO<sub>3</sub> was confirmed by atomic force microscopy (AFM) and four-point resistivity measurements. AFM shows unit cell high steps (4 Å) and surface roughness below 1/2 unit cell (1.9 Å) (see Supporting Information III). The resistivity of  $>10$  M $\Omega$  confirms the removal of dopants. The graphene sample was grown on a copper foil by chemical vapor deposition (CVD<sup>26</sup>) using methane at 1000 °C. The samples were placed in a tube furnace (Lindberg Blue) and pumped to  $\sim 100$ –500 mTorr. H<sub>2</sub>, 35 sccm, (99.999%) was flowed during the heating to the CVD temperature, 1000 °C. The growth was done by flowing a mixture of H<sub>2</sub> (2 sccm) and CH<sub>4</sub> (35 sccm) for 2 h. The system was cooled down under a flow of 35 sccm H<sub>2</sub>. A 500 nm thick layer of poly(methyl methacrylate) (PMMA) was spin-coated on top of the graphene, followed by the removal of copper by wet etching ( $\sim 30\%$  FeCl<sub>3</sub> and  $\sim 4\%$  HCl in deionized water). The graphene sample was then transferred onto the SrTiO<sub>3</sub>(001) substrate, followed by annealing at 680 °C in ultrahigh vacuum with a base pressure of  $1 \times 10^{-10}$  Torr. ARPES measurements were performed at the Beamlines 4.0.3 and 10.0.1 of the Advanced Light Source, Lawrence Berkeley National Laboratory, using photons with energies of 90 and 50 eV, respectively. The energy and angular resolutions set to be 18 meV and 0.2°, respectively. Raman measurements were performed using a laser source with a wavelength of 532 nm.

## ■ ASSOCIATED CONTENT

### Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acs.nanolett.7b01650.

The electron band structure of graphene/SrTiO<sub>3</sub>, the electron self-energy of graphene/SrTiO<sub>3</sub> as a function of temperature, an AFM image of SrTiO<sub>3</sub> (PDF)

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### Notes

The authors declare no competing financial interest.

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